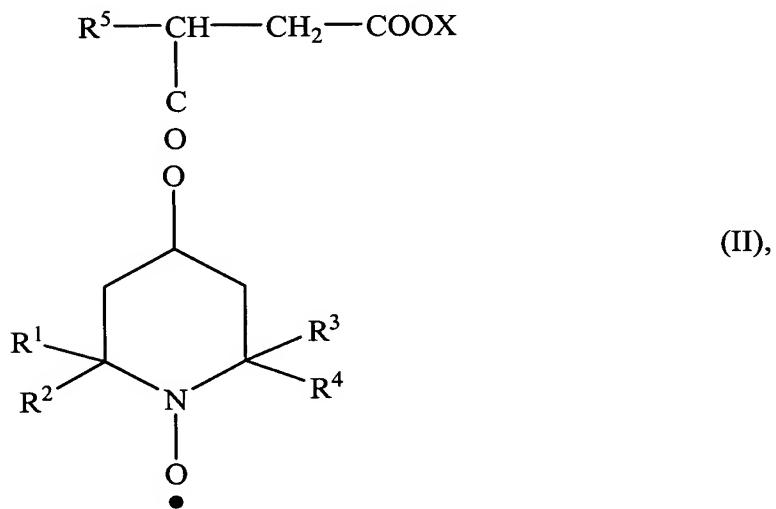
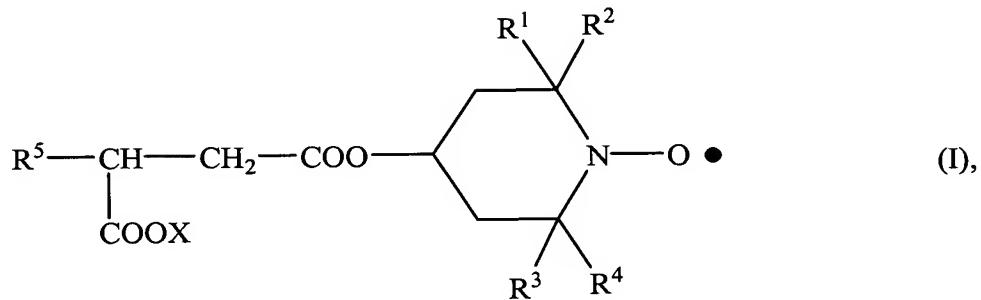


IN THE CLAIMS

Please amend the claims as follows:

Claim 1 (Currently Amended): A process comprising
inhibiting econducting free radical polymerization ~~on~~ in a mixture comprising at least
one chemical compound having at least one ethylenically unsaturated group, wherein
inhibiting said free radical polymerization is carried out by mixing in the presence of at least
one compound of formulae (I) or (II) with said mixture



where X is H, an alkali metal or ammonium,
 $\text{R}^1, \text{R}^2, \text{R}^3$ and R^4 , independently of one another, are each C_1 - to C_4 -alkyl and
 R^5 is C_8 - to C_{30} -alkyl.

Claim 2 (Previously Presented): A process as claimed in claim 1, wherein the at least one chemical compound having at least one ethylenically unsaturated group selected from the group consisting of acrylic acid, methacrylic acid, acrylonitrile, methacrylonitrile, styrene, an ester of acrylic acid and an ester of methacrylic acid.

Claim 3 (Previously Presented): A process as claimed in claim 1, wherein the mixture comprises (meth)acrylic acid and an organic liquid having a higher boiling point than (meth)acrylic acid.

Claim 4 (Previously Presented): A process as claimed in claim 1, wherein the mixture comprises $\geq 95\%$ by weight of (meth)acrylic acid.

Claim 5 (Previously Presented): A process as claimed in claim 1, further comprising at least one of rectification, extraction or absorption.

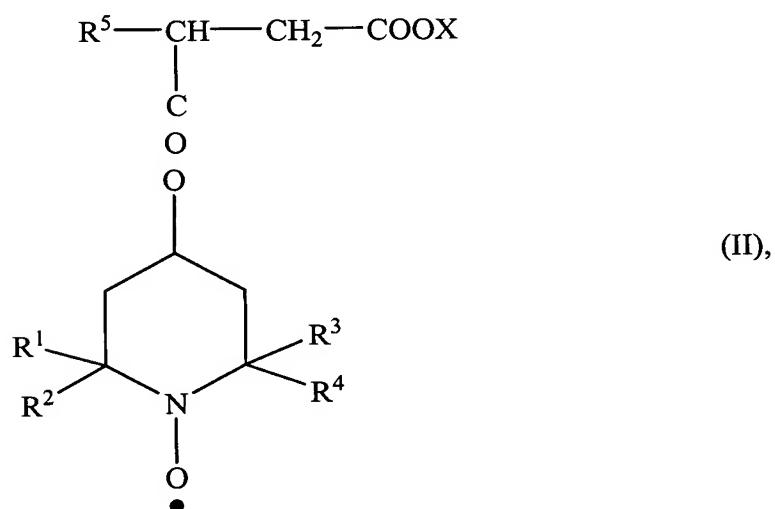
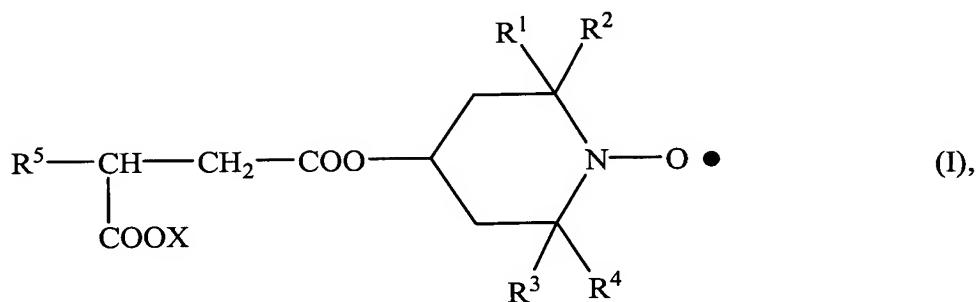
Claim 6 (Previously Presented): A process as claimed in claim 1, wherein R^1 , R^2 , R^3 and R^4 are either all methyl or all ethyl.

Claim 7 (Previously Presented): A process as claimed in claim 1, wherein X is H.

Claim 8 (Previously Presented): A process as claimed in claim 1, which is carried out from 100 to 200°C.

Claim 9 (Previously Presented): A process as claimed in claim 1, which is carried out at ≤ 100 mbar.

Claim 10 (Previously Presented): A mixture comprising at least one chemical compound having at least one ethylenically unsaturated group and at least one compound of formulae (I) or (II)



where X is H, an alkali metal or ammonium,
 $\text{R}^1, \text{R}^2, \text{R}^3$ and R^4 , independently of one another, are each C_1 - to C_4 -alkyl and
 R^5 is C_8 - to C_{30} -alkyl.

Claim 11 (Previously Presented): A mixture as claimed in claim 10, wherein said at least one chemical compound having at least one ethylenically unsaturated group is at least one selected from the group consisting of acrylic acid, methacrylic acid, acrylonitrile, methacrylonitrile, styrene, esters of acrylic acid and esters of methacrylic acid.

Claim 12 (Previously Presented): A mixture as claimed in claim 10, wherein R¹, R², R³ and R⁴ are either all methyl or all ethyl.

Claim 13 (Currently Amended): A process comprising
inhibiting econducting free radical polymerization on in a mixture comprising at least one chemical compound having at least one ethylenically unsaturated group, wherein inhibiting said free radical polymerization is carried out by mixing in the presence of at least one compound which is obtained by reacting an alkylsuccinic anhydride having a number average molar mass of from 212 to 1400 with 4-hydroxy-2,2,6,6-tetramethylpiperidin-N-only onyl, with said mixture.

BASIS FOR THE AMENDMENT

Claims 1-13 are active in the present application. Claims 1 and 13 have been amended to correctly state that the process is a process comprising inhibiting free radical polymerizations in mixtures containing ethylenically unsaturated species. Support for the amendment is found through the specification as filed. No new matter is added.

REMARKS

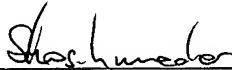
Applicants thank Examiner Puttlitz for the helpful and courteous discussion of October 2, 2003. During the discussion, the Examiner confirmed that the claimed process is correctly drawn to a process for inhibiting free radical polymerization and that the Examiner's Amendment in the Notice of Allowance of October 2, 2003, may have been entered in error.

An Information Disclosure Statement containing the references cited on the International Preliminary Examination Report was submitted to the U.S. Patent and Trademark Office on April 5, 2002. A copy of the form PTO-1449 submitted together with the IDS was returned with the Notice of Allowance of October 2, 2003. Applicants note however that the consideration of the references provided thereon has not been acknowledged with the Examiner's initials by each cited reference and the Examiner's full signature at the bottom of the form PTO-1449. Applicants attach herewith copies of the form PTO-1449 and a date-stamped filing receipt evidencing the timely submission thereof. Applicants respectfully request the Office return a signed, initialed, and dated copy of the form PTO-1449 to properly make of record consideration of the references in the examination of the above-identified application.

Applicants submit that all now-pending claims remain condition for allowance and respectfully request their passage to Issue.

Respectfully submitted,

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